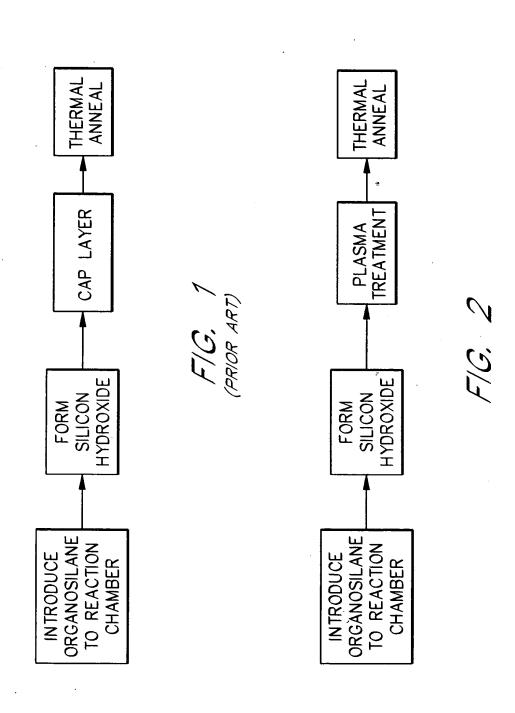
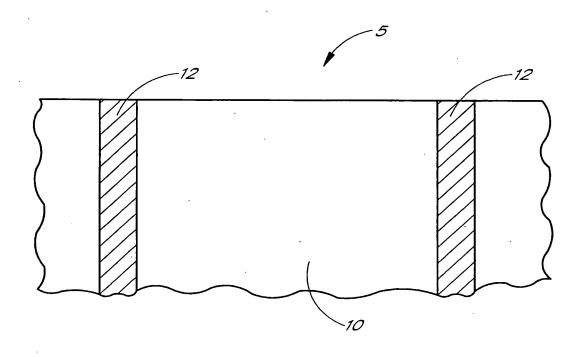
NAR 1 4 2003 LOW DIELECTRIC CONTANT, MATERIAL FOR INTEGRATED ROUIT FABRICATION LI



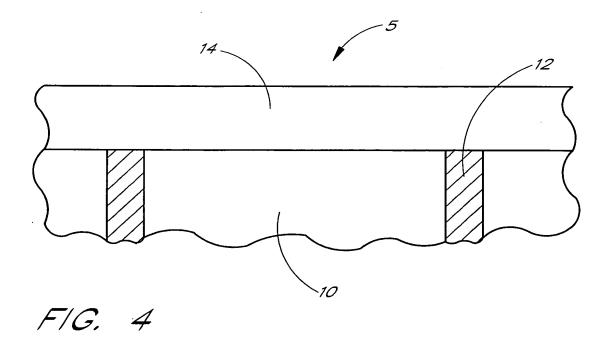
LOW DIELECTRIC CONSTANT MATERIAL FOR INTEGRATED CIRCUIT FABRICATION

Li

10/033,656 MICRON.076DV1



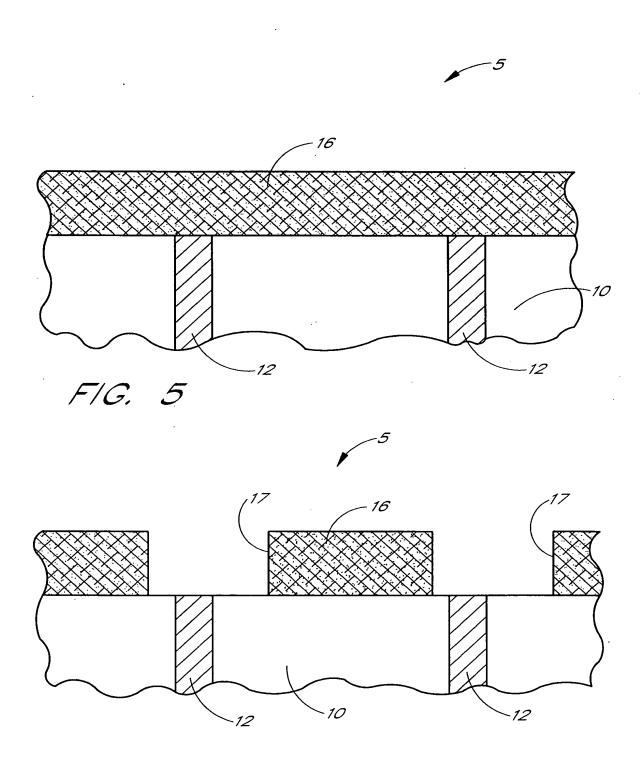
F/G. 3





LOW DIELECTRIC CONSTANT. MATERIAL FOR INTEGRATED CIRCUIT FABRICATION
Li
10/033,656 MICRON.076DV1

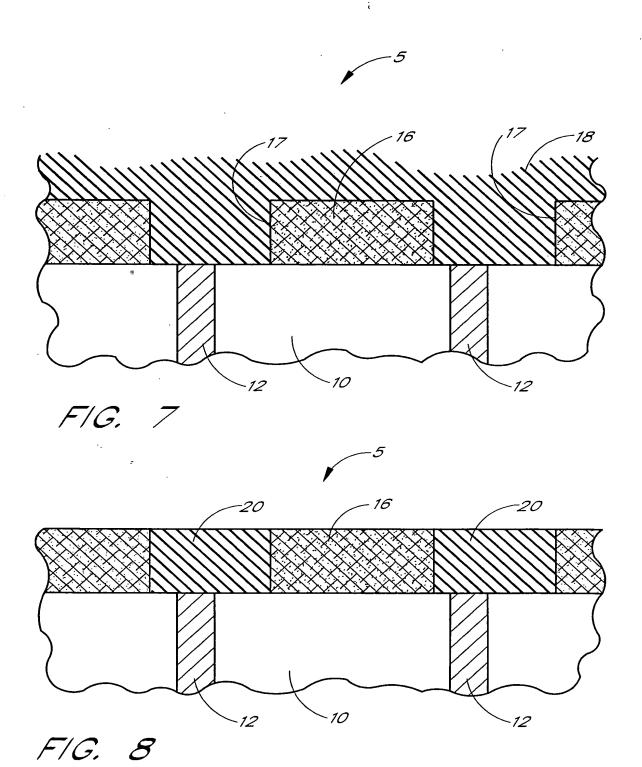
3/10



F/G. 6



LOW DIELECTRIC CONSTANT MATERIAL FOR INTEGRATED CIRCUIT FABRICATION
Li
10/033,656 MICRON.076DV1

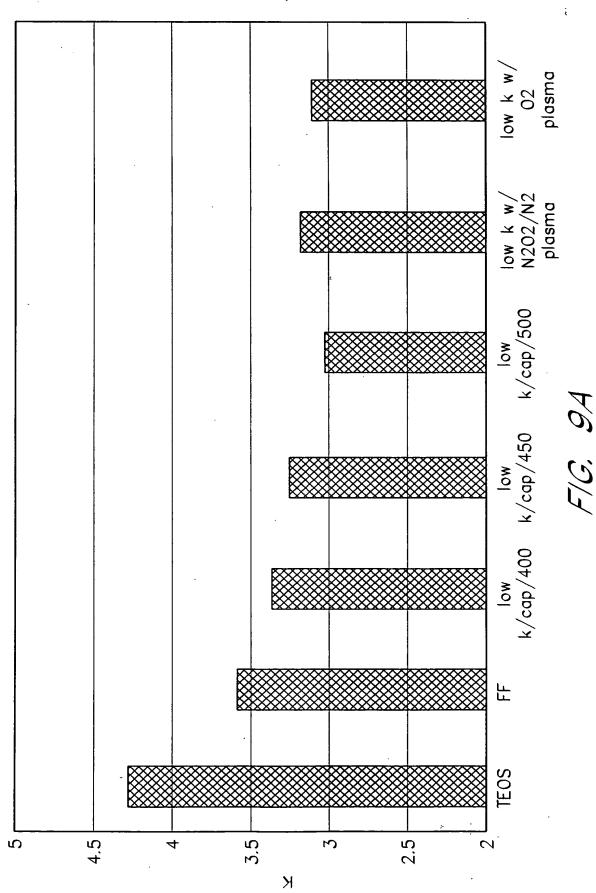




## LOW DELECTRIC CONSTANT MATERIAL FOR INTEGRATED CIRCUIT FABRICATION

10/033,656

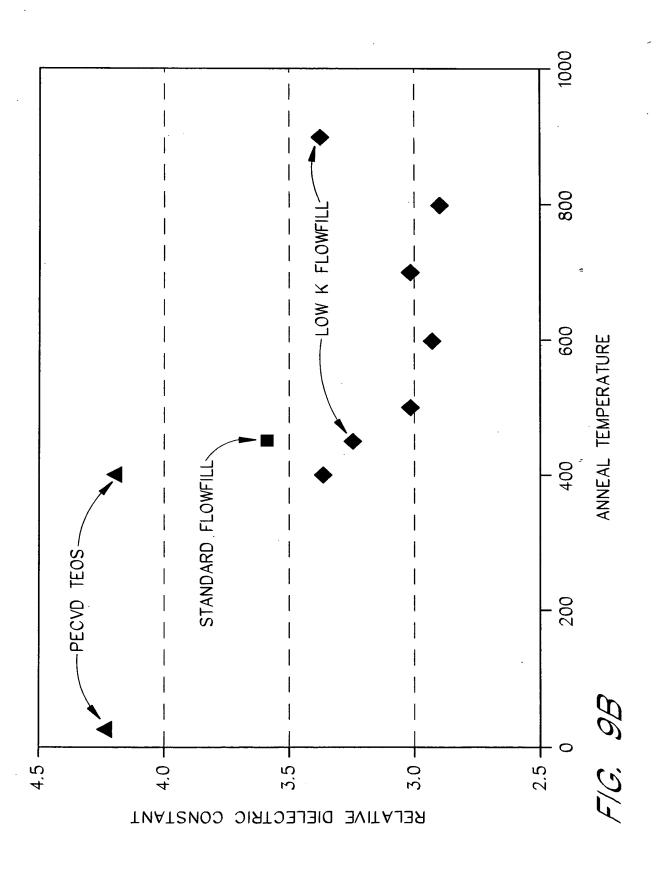
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LOW DIELECTRIC CONSTANT MATERIAL FOR INTEGRATED CIRCUIT FABRICATION

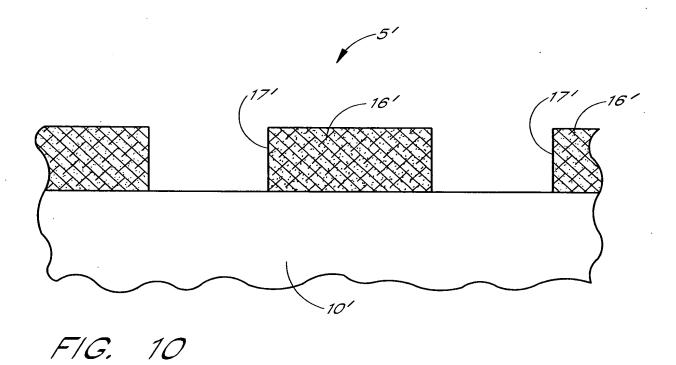
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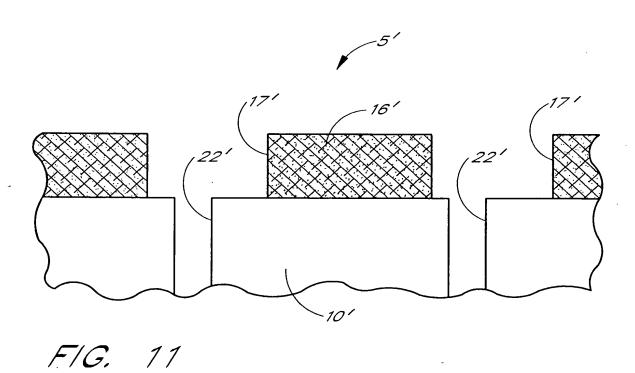
MICRON.076DV1





## LOW DIELECTRIC CONSTANT MATERIAL FOR INTEGRATED CIRCUIT FABRICATION Li 10/033,656 MICRON.076DV1





NAR 1 4 2003 FOW DIELECTRIC CONSTANT MATERIAL FOR INTEGRATED CIRCUIT FABRICATION Li

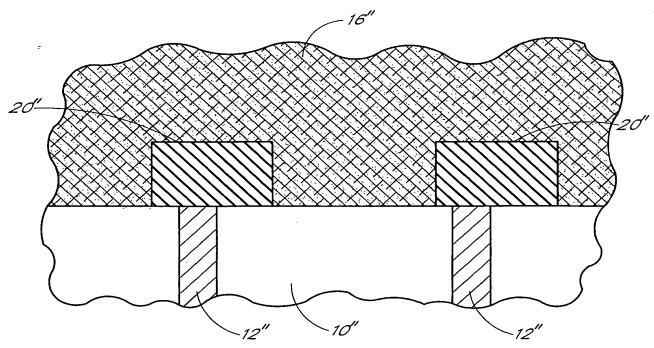
10/033,656 MICRON.076DV1

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20"

-12

F/G. 12



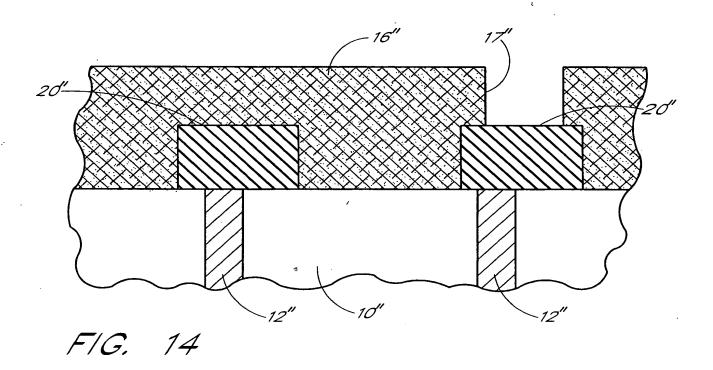
F/G. 13

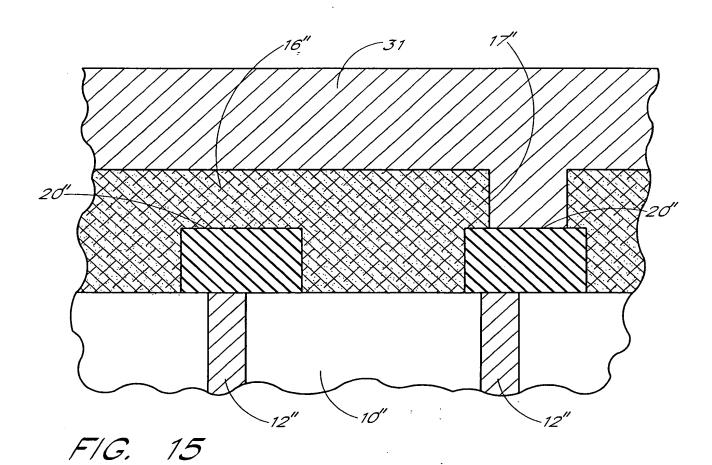


LOW DIELECTRIC CONSTANT MATERIAL FOR INTEGRATED CIRCUIT FABRICATION

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MICRON.076DV1

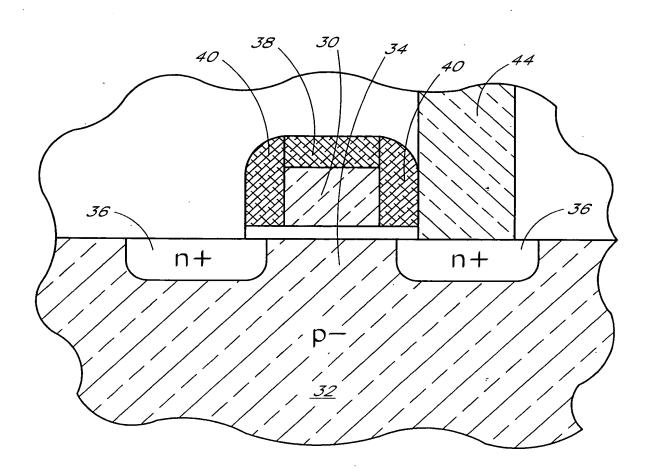






## LOW DIELECTRIC CONSTANT MATERIAL FOR INTEGRATED FIRCUIT FABRICATION MICRON.076DV1

10/033,656



F/G. 16